



Direct bonding of biaxially oriented polyethylene terephthalate films with plasma surface modification using various gases



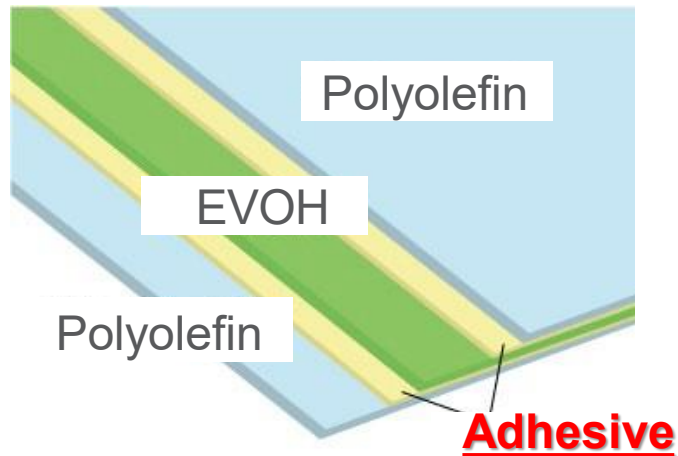
T. KOYAMA (1), K. KANASUGI (1), K. HIRAKURI (1)

1. Faculty of Engineering, Tokyo Denki University,

1. Background

Examples of laminating plastic films used in industry

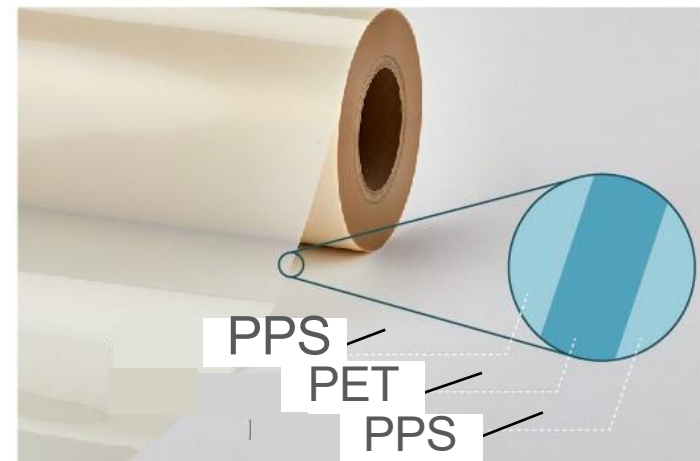
Multilayer Barrier Film



https://www.ube.co.jp/ubefilm/products/order/barrier_film.html

- To improve gas barrier properties
- To boost strength

Heat-resistant Insulating Film



<https://www.films.toray/products/tt/>

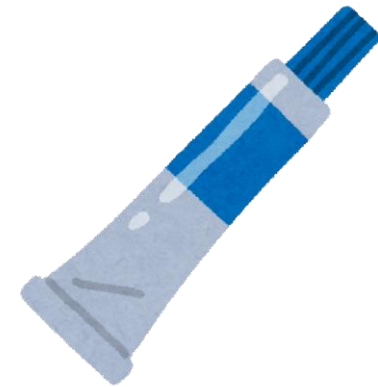
- To enhance electrical insulation
- To optimize heat resistance

Plastic film manufacturers are laminating plastic films with different properties using **adhesives** to obtain the required characteristics.

1. Background

Disadvantages of using adhesives

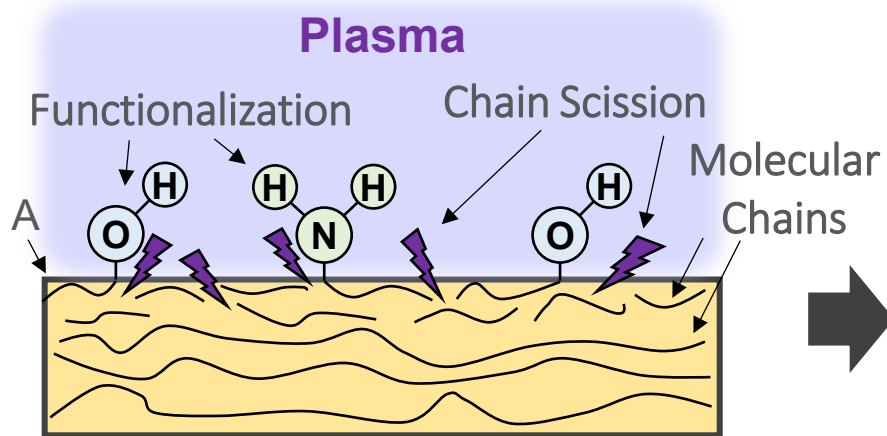
- Peeling due to adhesive deterioration
- Elution of adhesive components
- Increase in thickness due to the adhesive layer



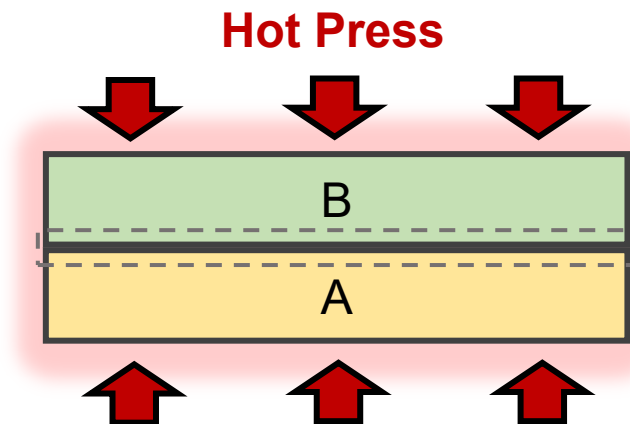
To solve the above issues, we focused on **adhesive-free bonding technology (direct bonding)**.

2. Introduction to Direct Bonding

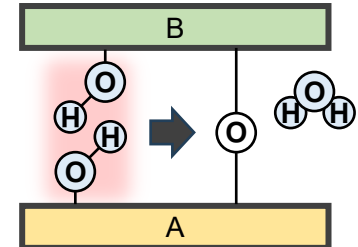
1. Surface modification



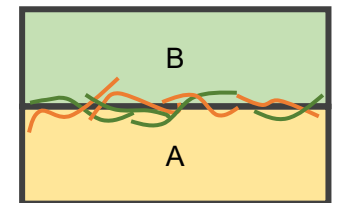
2. Bonding



Covalent Bond Formation



Enhancement Intermolecular Forces



In the case of direct bonding technology using plasma, it has been reported that direct bonding can be achieved by heat pressing after plasma surface modification.

In previous research

It has been reported that PET films can be directly bonding by vacuum plasma surface modification using **O₂** gas.

Tamio Endo et al., "Composite engineering – direct bonding of plastic PET films by plasma irradiation", Procedia Engineering, 171 (2017) 88-103



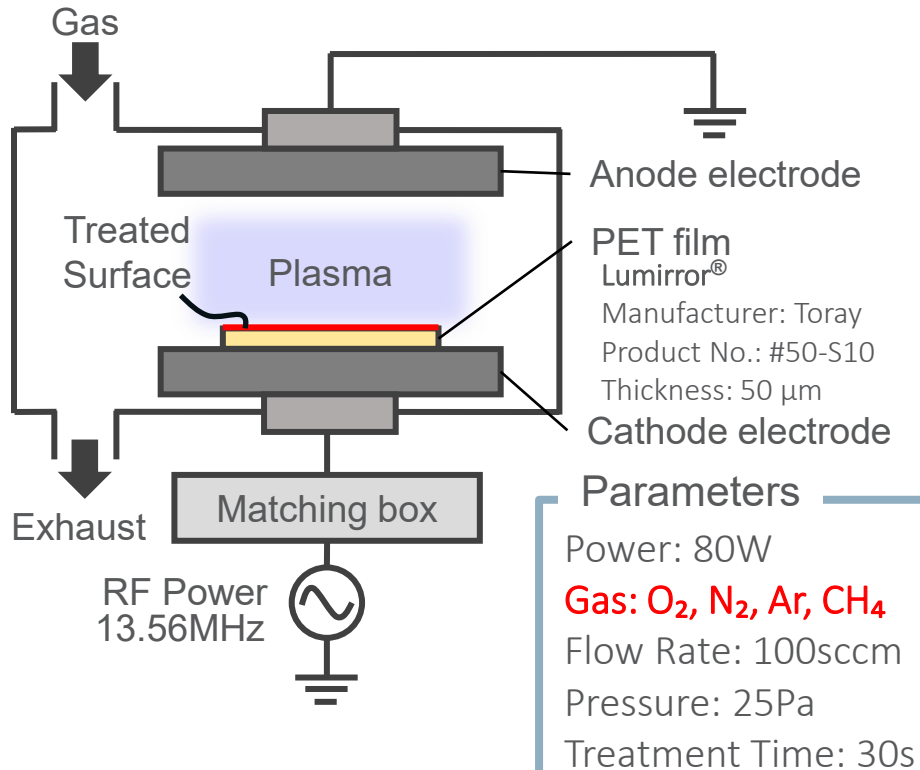
However, the effects of gas species used in vacuum plasma surface modification have not been investigated.

In this study

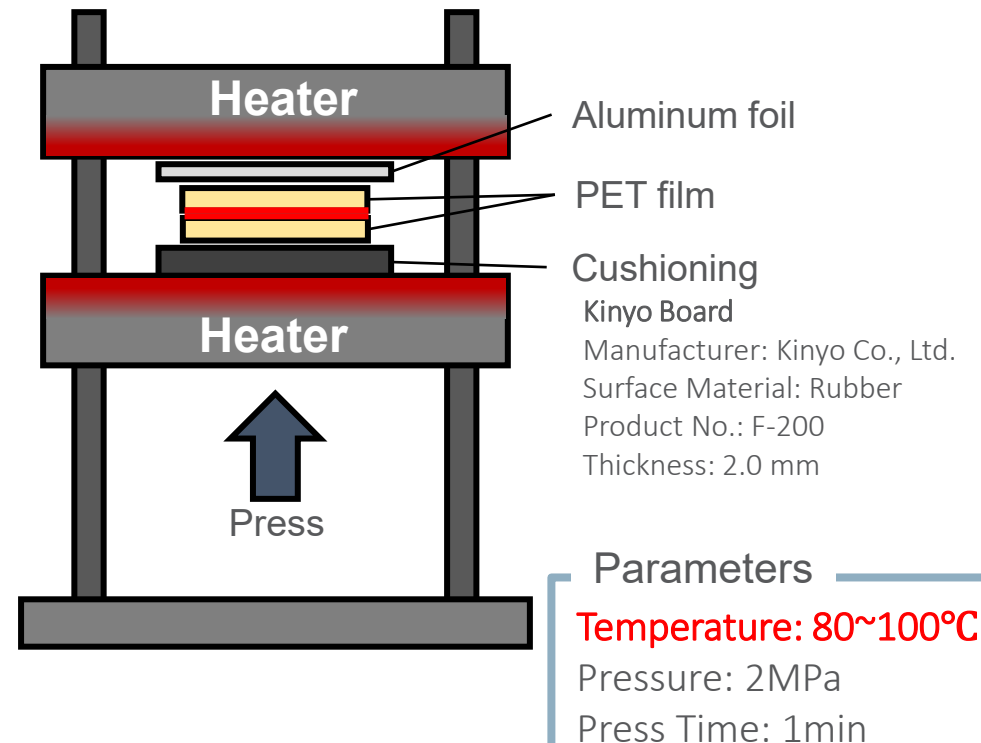
We investigated the direct bonding of PET films modified by vacuum plasma surface modification using various gas species (**N₂**, **Ar**, **CH₄**).

4. Conditions for Direct Bonding

① Vacuum Plasma Treatment



② Hot Press



In this experiment, the gas species for vacuum plasma surface modification and hot press temperature were varied.

5. Results of Adhesive Strength

Equipment

Manufacturer: IMADA

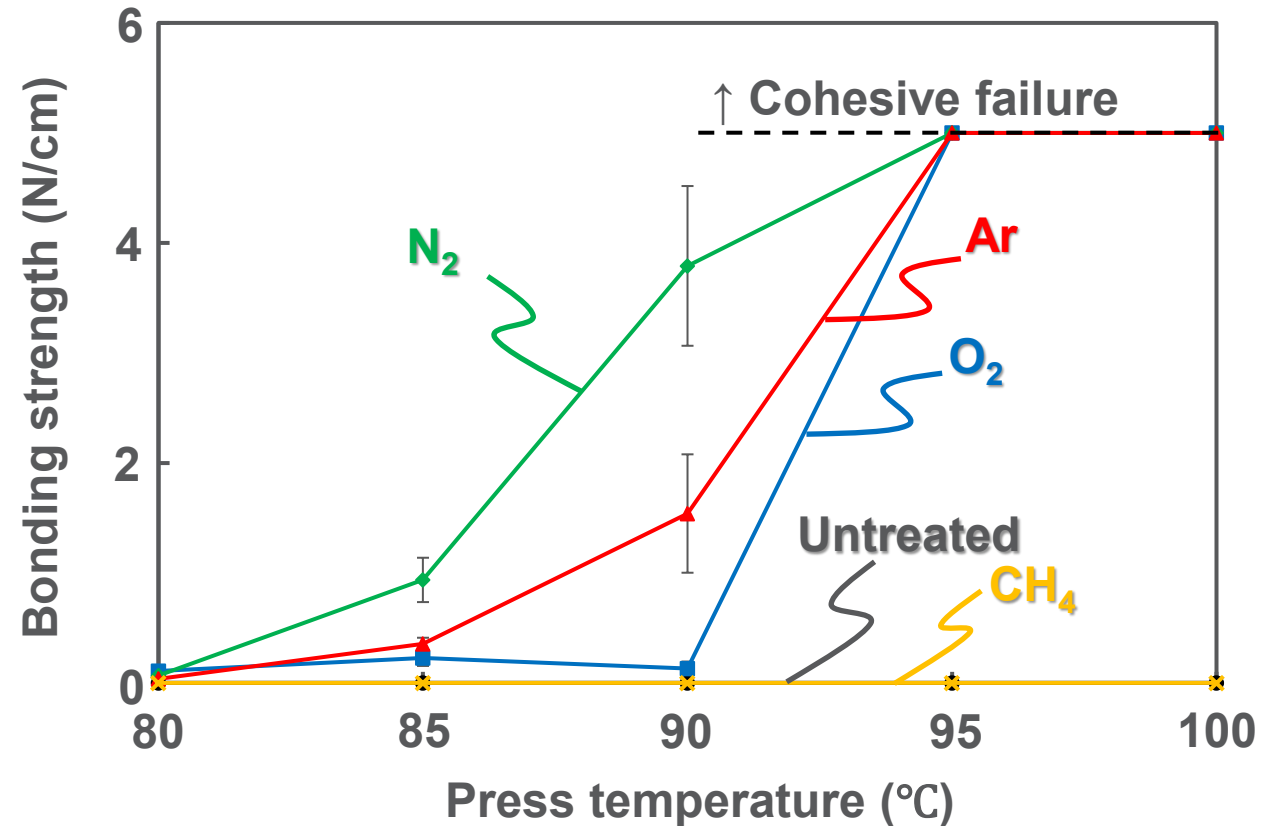
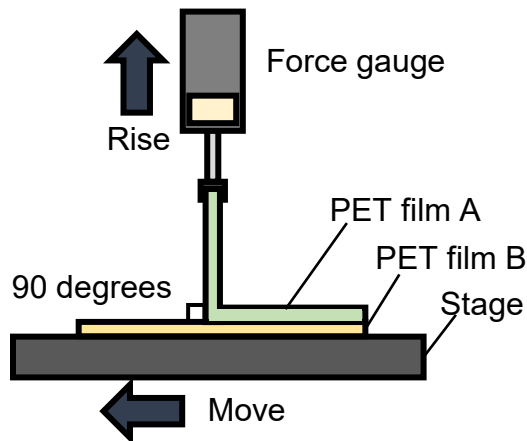
Model: ZTS-5N, MX2-500N

Measurement Conditions

Peel speed: 50mm/min

Substrate width: 1cm

n=3



This bond strength increases with the heat press temperature, and we confirmed that the gas species in vacuum plasma surface treatment are effective in the order of N₂, Ar, and O₂.

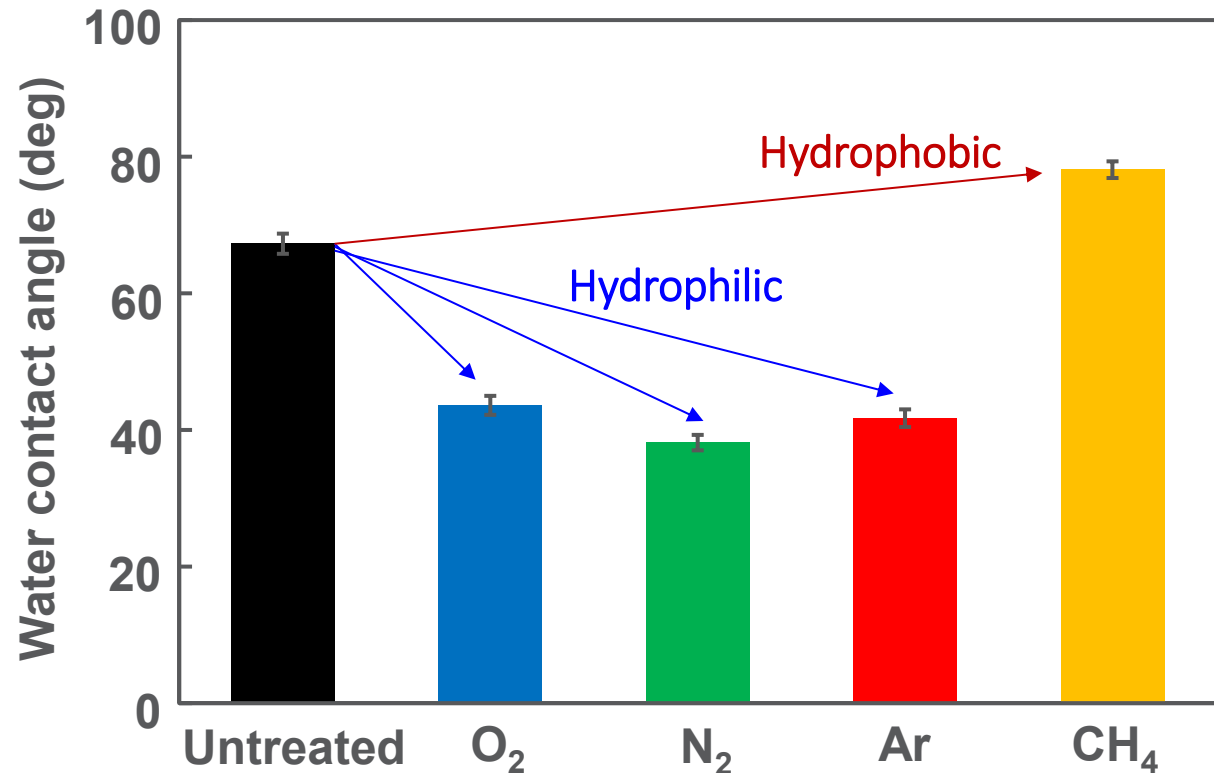
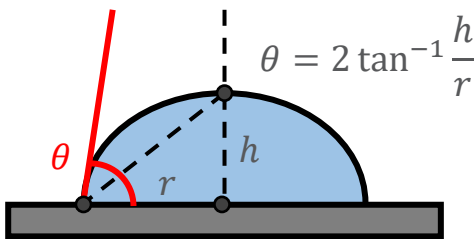
6. Results of Wettability of PET Film before Bonding

Equipment

Manufacturer: Kyowa
Interface Science Co., Ltd.
Model: CA-X

Measurement Conditions

Method: $\theta/2$ method
Droplet Volume: 0.4 μL
Liquid: Pure water
 $n = 5$



For O₂, N₂, and Ar gases, it was confirmed that the PET film surface was hydrophilic. On the other hand, for CH₄ gas, it was found to be hydrophobic.

7. Calculation of Surface Free Energy of PET Film before Bonding

Extended Fokes equation (Kitazaki-Hatake model)

$$(1 + \cos \theta) \cdot \gamma_L$$

$$= 2 \left(\sqrt{\gamma_S^d \cdot \gamma_L^d} + \sqrt{\gamma_S^p \cdot \gamma_L^p} + \sqrt{\gamma_S^h \cdot \gamma_L^h} \right)$$

θ : Measured contact angle

γ_L : Total surface tension value of the liquid

γ_L^d : Dispersive component of liquid

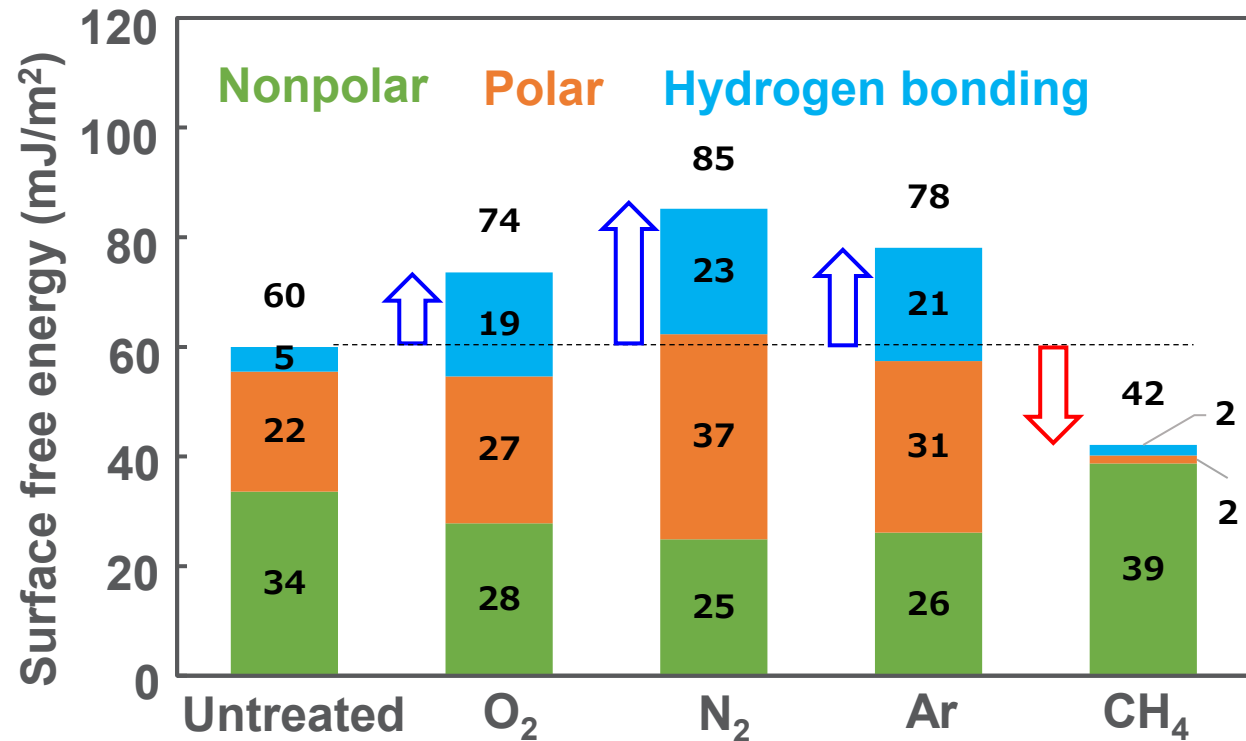
γ_L^p : Polar component of liquid

γ_L^h : Hydrogen bonding component of liquid

γ_S^d : Dispersive component of sample

γ_S^p : Polar component of sample

γ_S^h : Hydrogen bonding component of sample



It was found that the surface free energy increased in samples treated with O₂, N₂, and Ar gases, while it decreased in samples treated with CH₄ gas.

→ This increase in surface free energy may have contributed to the bonding strength.

8. Results of Surface Roughness of PET Film before Bonding (AFM)

Equipment

Manufacturer: JEOL

Model: JSPM-5200

Measurement Conditions

Scan size: 1.50μm × 1.50μm

Filter: 0.5Hz

Loop gain: 16

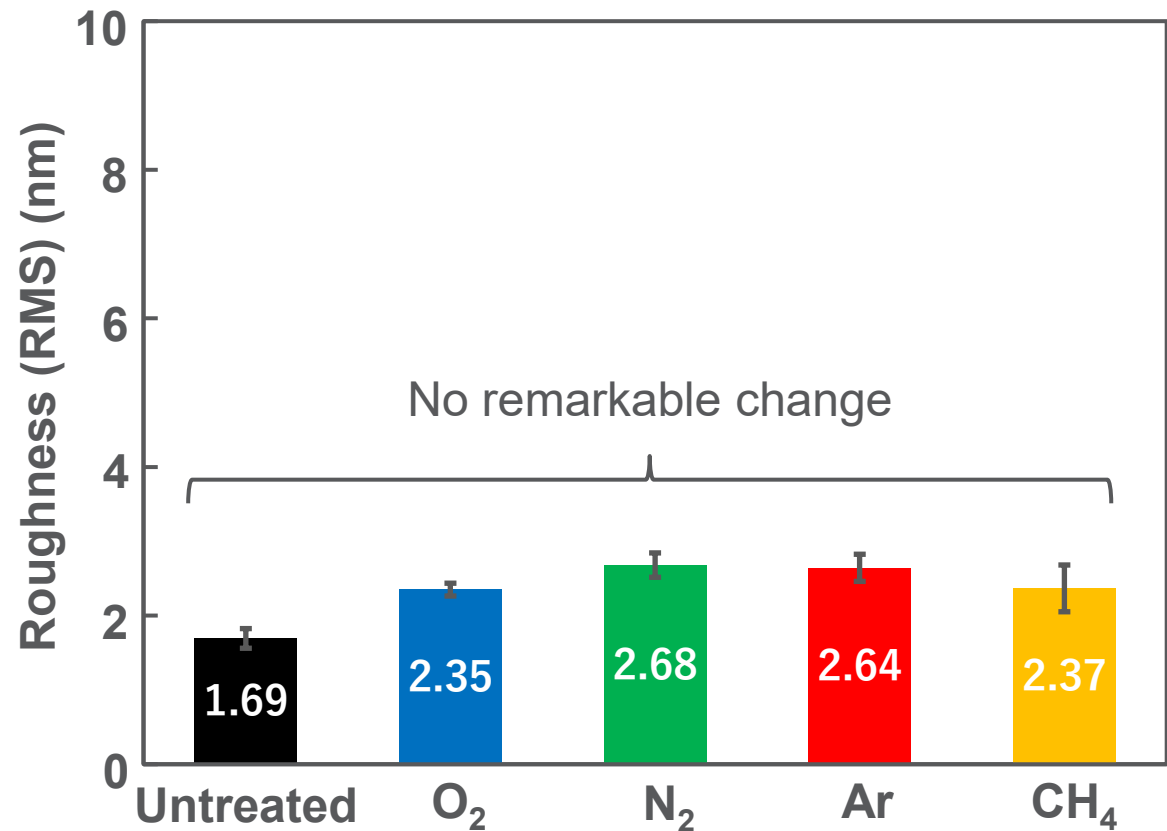
n=3

Root mean square (RMS) surface roughness

$$\text{RMS} = \sqrt{\frac{1}{N} \sum_{i=1}^N z_i^2}$$

z_i : Deviation in height values at individual points

N : Number of measurement points



Generally, surface free energy is influenced by physical and chemical properties, but the surface roughness of the samples was similar.

9. Results of Surface Composition of PET Film before Bonding (XPS)

Equipment

Manufacturer: Shimadzu Corporation

Model: ESCA-3400

Measurement Conditions

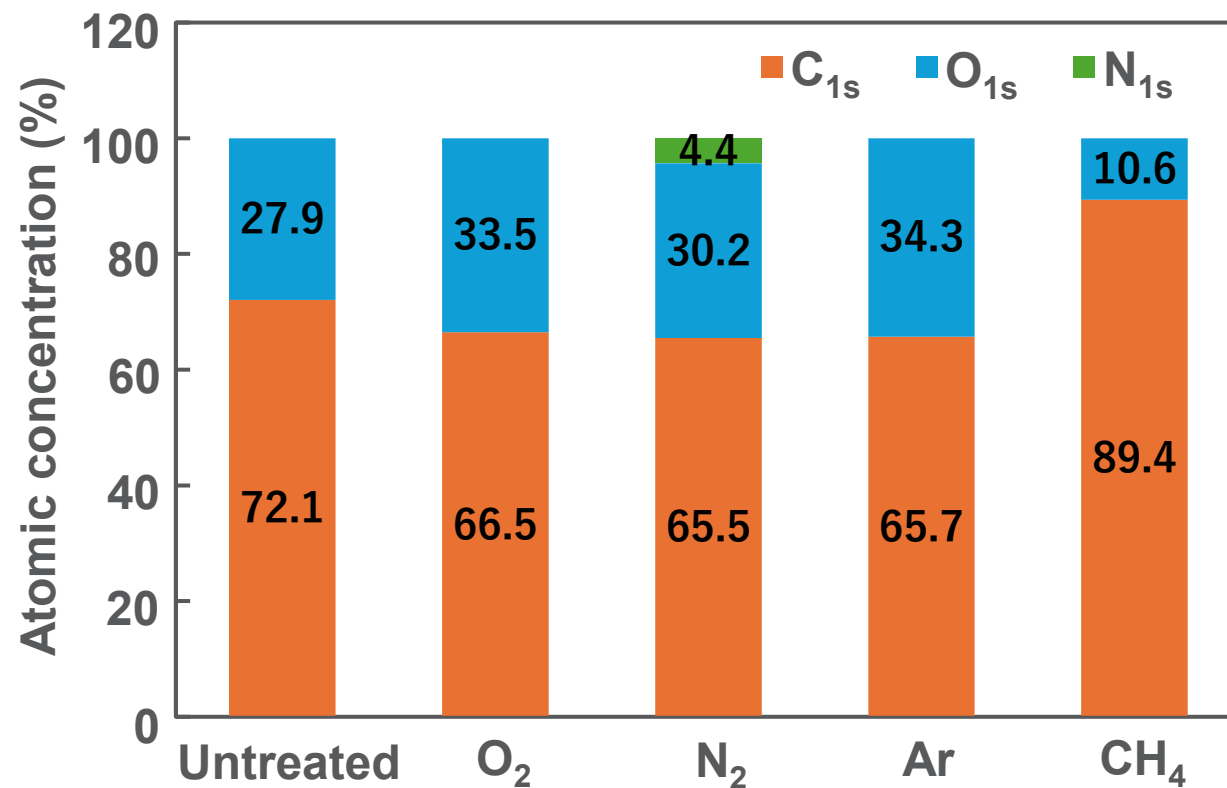
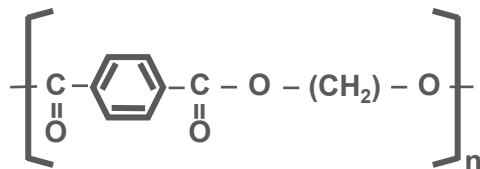
X-ray source: Mg K α

Emission current: 10 [mA]

Accelerating voltage: 10 [kV]

Energy resolution: 0.1 [eV]

Molecular structure of PET



Next, we analyzed the surface composition and found that samples treated with O₂, N₂, and Ar gases had higher oxygen content than untreated samples. In addition, nitrogen was detected in samples treated with N₂ gas.

9. Results of Surface Composition of PET Film before Bonding (XPS)

Equipment

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Model: ESCA-3400

Measurement Conditions

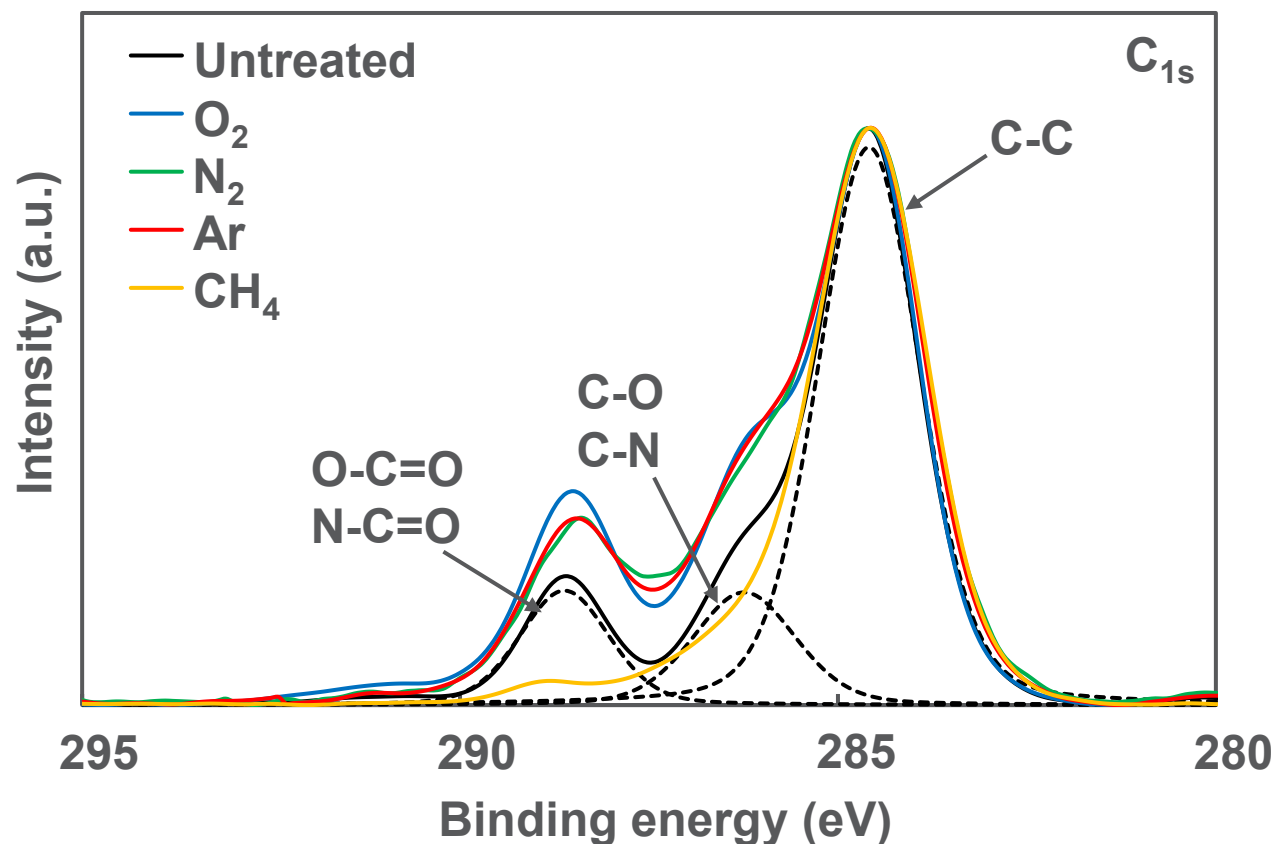
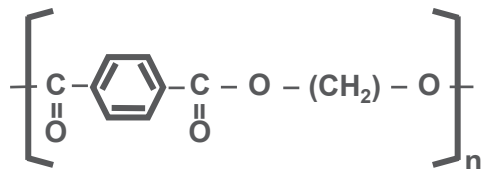
X-ray source: Mg K α

Emission current: 10 [mA]

Accelerating voltage: 10 [kV]

Energy resolution: 0.1 [eV]

Molecular structure of PET



Furthermore, when the C spectrum was separated into waveforms, it was found that the polar groups C–O, C–N, and O–C=O bonds increased in samples treated with O_2 , N_2 , and Ar gases.

In this study

We investigated the direct bonding of PET films modified by vacuum plasma surface treatment using various gas species (N_2 , Ar, CH_4).



The adhesive strength increased in the order of O_2 , Ar, and N_2 for the vacuum plasma surface treatment gas types.



This difference in bonding strength may be influenced by an increase in surface free energy caused by the formation of polar groups.



Thank you!

Takumi Koyama
24kmj15@ms.dendai.ac.jp



Sponsors / Partners:

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In this study, We used the Atomic Force Microscope (JSPM-5200) and X-ray Photoelectron Spectroscopy (ESCA-3400) at Tokyo Denki University Analysis Center